

Retraction

Retraction: Gao, W., et al. Exploration of Growth Window for Phase-Pure Cubic Boron Nitride Films Prepared in a Pure N₂ Plasma. *Coatings* 2018, 8, 82, doi:10.3390/coatings8020082

Coatings Editorial Office

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Received: 4 September 2018; Accepted: 5 September 2018; Published: 7 September 2018



The published article [1] has been retracted at the request of the corresponding author due to a dispute regarding the authorship of the paper. Unfortunately, the dispute could not be settled via a change of the authorship and an additional eligible author did not agree to the publication of the paper in its current form. Thus, out of respect for the author's wishes and in agreement with the *Coatings* Editorial Office, the paper will be marked as retracted. We apologize for any inconvenience caused by the removal of this article.

Coatings is a member of the Committee on Publication Ethics (COPE) and strives to uphold the highest ethical standards. To resolve this dispute, we have communicated with ethical committee of the Social and Societal Ethics Committee of the University of Hasselt where much of the work was carried out and wish to thank them for their cooperation.

Reference

1. Gao, W.; Li, Y.; Zhang, Y.; Yin, H. Exploration of Growth Window for Phase-Pure Cubic Boron Nitride Films Prepared in a Pure N₂ Plasma. *Coatings* 2018, 8, 82. [[CrossRef](#)]



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